

## Ammonia oxidation on Pt(410)

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### Abstract

The adsorption of both O<sub>2</sub> and NH<sub>3</sub> on Pt(410) was studied using temperature-programmed desorption (TPD) and X-ray photoelectron spectroscopy (XPS). Molecular NH<sub>3</sub> desorbed from Pt(410) between 100 and 450 K, and dissociation was not observed. Radiation (X-rays, electrons) induced NH<sub>3ad</sub> dissociation, and as a result several dissociation products (NH<sub>2ad</sub>, NH<sub>ad</sub>, and N<sub>ad</sub>) were observed in the N 1s core-level spectrum. NH<sub>ad</sub> is a rather stable dissociation product that starts to dehydrogenate above 350 K. The N<sub>ad</sub> and H<sub>ad</sub> formed in this process desorbed on formation (as N<sub>2</sub> and H<sub>2</sub>). Both molecular and dissociative O<sub>2</sub> adsorption were observed after the surface was exposed to O<sub>2</sub>(g) at 100 K. Molecularly adsorbed O<sub>2</sub> desorbed below 200 K, whereas atomic oxygen desorbed (as O<sub>2</sub>) between 600 and 900 K, in two distinct desorption peaks. In the O 1s core-level spectrum, both molecular O<sub>2</sub> and two different types of O<sub>ad</sub> were distinguished. NH<sub>3ad</sub> dissociation was observed on an oxygen-presaturated surface. The NH<sub>3ad</sub> oxy-dehydrogenation started at 150 K. NO<sub>ad</sub> and NO(g) were also observed, but only during experiments in which an excess of O<sub>ad</sub> was available. NO<sub>ad</sub> desorbed/decomposed between 400 and 500 K. For the steady-state ammonia oxidation reaction, N<sub>2</sub> and H<sub>2</sub>O were the major products at low temperatures, whereas the selectivity toward NO and H<sub>2</sub>O changed at higher temperatures. This selectivity change can be attributed to changes in surface composition.

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### 1. Introduction

Catalytic ammonia oxidation is an important process in the chemical industry. It is used on a large scale to produce nitric oxide, a precursor for nitric acid. The catalyst of choice for this process is an alloy of Pt and Rh. A number of surface science studies have been performed to unravel the surface chemistry of NH<sub>3</sub> on Pt surfaces in both the absence and presence of co-adsorbed oxygen [1–3].

The surface chemistry of ammonia on a metal surface is complex, involving several different surface species. Adsorption and decomposition of NH<sub>3</sub> can in principle lead to five different species: NH<sub>3ad</sub>, NH<sub>2ad</sub>, NH<sub>ad</sub>, N<sub>ad</sub>, and H<sub>ad</sub>. In the

presence of oxygen, several other species can be involved in the surface chemistry, including O<sub>ad</sub>, OH<sub>ad</sub>, H<sub>2</sub>O<sub>ad</sub>, and NO<sub>ad</sub>. The complexity of the surface chemistry is reflected in the gas-phase product selectivity during catalytic NH<sub>3</sub> oxidation. Different gaseous products, including N<sub>2</sub>, NO, and N<sub>2</sub>O, can be formed. The selectivity depends on the type of catalyst, its surface structure, and the experimental conditions, such as reactant pressures, NH<sub>3</sub>/O<sub>2</sub> ratio, and catalyst temperature.

It has been found that ammonia decomposition does not take place on Pt surfaces at temperatures below 400 K. Some NH<sub>3</sub> decomposition has been observed *above* the NH<sub>3</sub> desorption temperature; in that case, stepped surfaces were found to be more active than “smooth” surfaces [1,4,5]. On several metals, including Pt, Ag, Ir, and Cu, the presence of oxygen has been found to enhance NH<sub>3</sub> dissociation [3,6–11].

In this paper we present the results obtained for ammonia oxidation on a Pt(410) surface, which consists of {100} terraces

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and {110} steps. Faceting of the surface was observed, resulting in the formation of larger {100} terraces on which a ( $5 \times 20$ ) reconstruction occurred. A more detailed discussion concerning the actual surface structure of our Pt(410) sample has been provided previously [12].

XPS was used to study the nature and concentration of surface species, and the gas-phase reaction products were detected by quadrupole mass spectrometry (QMS). The aim of our experiments was to obtain fundamental insights into surface processes, which can help elucidate the reaction pathways involved in catalytic ammonia oxidation. Based on our previous studies, we also can compare the  $\text{NH}_3$  chemistry on Pt(410) with that on (previously studied) Ir surfaces [9,13–16].

## 2. Experimental

The thermal desorption studies were performed using the experimental setup in Leiden, which has been described in more detail elsewhere [12]. High-energy resolution fast XPS measurements [17,18] were performed on the SuperESCA beamline of ELETTRA, the synchrotron radiation facility in Trieste, Italy. The vacuum system, with a base pressure of  $\sim 1 \times 10^{-10}$  mbar, is equipped with a sputter ion gun for sample cleaning, a mass spectrometer, and LEED optics. Details about the sample used in this study and the cleaning procedure can be found elsewhere [12].

The N 1s spectra were measured with a photon energy of 496 eV, and the O 1s spectra were measured with a photon energy of 650 eV. Temperature-programmed XPS (TP-XPS) measurements [19] were performed at a heating rate of  $0.25 \text{ K s}^{-1}$ . The different core level regions were measured in a separate experiment; that is, either O 1s or N 1s could be measured during an experiment. The XPS spectra were evaluated after a linear background was subtracted by fitting the peaks with a Doniach–Šunjić function convoluted with a Gaussian function [20].

Core-level binding energies of the different species were measured with respect to the Fermi level. The position of the Fermi edge was determined using an photon energy of 110 eV. In recent experiments, we found that the position of the Fermi level should be measured using the photon energy used for the actual measurements as well, because the calibration of the photon energy was not very accurate (e.g., when the excitation energy was set to 650 eV, the *actual* energy was  $\sim 647$  eV). As a result of the approach used here (i.e., measuring the Fermi edge with a different photon energy than for the actual measurements), the reported *absolute* binding energies (BEs) can exhibit a (constant) shift with respect to literature values. Therefore, the  $\Delta$ BEs between different species instead of *absolute* BEs should be used for comparison with literature data. This issue affected only the comparison with literature data; the position of the different species remained constant throughout the experiments. The N 1s and O 1s signals were normalized using the intensities obtained for a saturated NO layer at 100 K (which was arbitrarily set to 1).

Both Sun et al. [21] and Schwaner et al. [22] found that adsorbed  $\text{NH}_3$  decomposed when exposed to a beam of ( $\sim 50$  eV) electrons. In the experimental setup used for the thermal de-

sorption experiments, radiation damage due to electrons from the QMS filaments ( $\sim 70$  eV) can be excluded, because the QMS was situated in a separate compartment, with only a small hole connecting it to the main chamber (where the crystal was located). In this setup, the likelihood of electrons generated by the QMS filaments reaching the sample surface is very low. During the XPS measurements,  $\text{NH}_{3\text{ad}}$  dissociation was induced by the intense radiation (either X-rays or  $\sim 100$  eV photoelectrons). This is described in more detail in Section 3.1.

## 3. Results

### 3.1. $\text{NH}_3$ surface chemistry

Thermal desorption spectra obtained after exposure to  $\text{NH}_3$  at 100 K are shown in Fig. 1a. Ammonia bonded directly to the surface (through the nitrogen atom) desorbed molecularly between 200 and 450 K. After an  $\text{NH}_3$  exposure of  $\sim 3 \text{ L}$ , a new desorption feature appeared, with a desorption maximum at around 175 K. In line with literature assignments, this peak can be attributed to desorption of a second  $\text{NH}_3$  layer that was hydrogen-bonded to the first, chemisorbed layer [5,13,23–26]. Even higher exposures led to the formation of  $\text{NH}_3$  multilayers that desorbed at around 120 K [5,27]. The observed peaks are very similar to the desorption spectra observed for other Pt surfaces, and the presence of steps seemed to have little effect on the desorption spectra.  $\text{N}_2$  or  $\text{H}_2$  desorption was not observed, indicating that  $\text{NH}_3$  dissociation did not take place on the clean surface.

Fig. 2a shows one of the N 1s core-level spectra obtained during XPS experiments of an adsorbed  $\text{NH}_3/\text{NH}_{\text{xad}}$  layer. It also shows the fitting components used to deconvolute the spectra. The BEs of all of the fitting components used to evaluate the XPS data are summarized in Table 1. Fig. 2b shows a series of spectra taken during heating of an adsorbed  $\text{NH}_3/\text{NH}_{\text{xad}}$  layer in vacuum. Ammonia was dosed at 175 K, to avoid formation of the  $\text{NH}_3$  double layer. During the uptake (not shown), initially only molecular ammonia was observed (at 400 eV). However, the intense radiation (either X-rays or the resulting  $\sim 100$ -eV photoelectrons) induced dissociation of the adsorbed  $\text{NH}_3$ , and another peak developed at 398.3 eV, assigned to  $\text{NH}_{\text{ad}}$ . We suggest that another small peak was present at 399.1 eV, which is assigned to  $\text{NH}_{2\text{ad}}$  on the basis of its BE. This peak was never clearly resolved, and the concentration of this species was low. Heating of the dissociated  $\text{NH}_{\text{xad}}$  layer (Figs. 1c and 2b) resulted in the formation of an additional (small) peak at 397.4 eV, assigned to  $\text{N}_{\text{ad}}$ . This assignment is in line with literature data [8,13,21] in which the  $\Delta$ BE among various  $\text{NH}_{\text{xad}}$  species was reported to be  $\sim 1$  eV on several different metal surfaces. The same BE component was observed after NO dissociation on this surface [12]. Fig. 1c shows the results obtained after evaluation of the data shown in Fig. 2b using the components shown in panel (a).  $\text{NH}_{3\text{ad}}$  desorbed between 175 and 400 K, and  $\text{NH}_{2\text{ad}}$  decomposed (into  $\text{NH}_{\text{ad}}$  and  $\text{H}_{\text{ad}}$ ) between 175 and 250 K.  $\text{NH}_{\text{ad}}$  decomposition was observed above 350 K. As a result, a small amount of  $\text{N}_{\text{ad}}$  that desorbed almost immediately on formation (as  $\text{N}_2$ ) was observed.

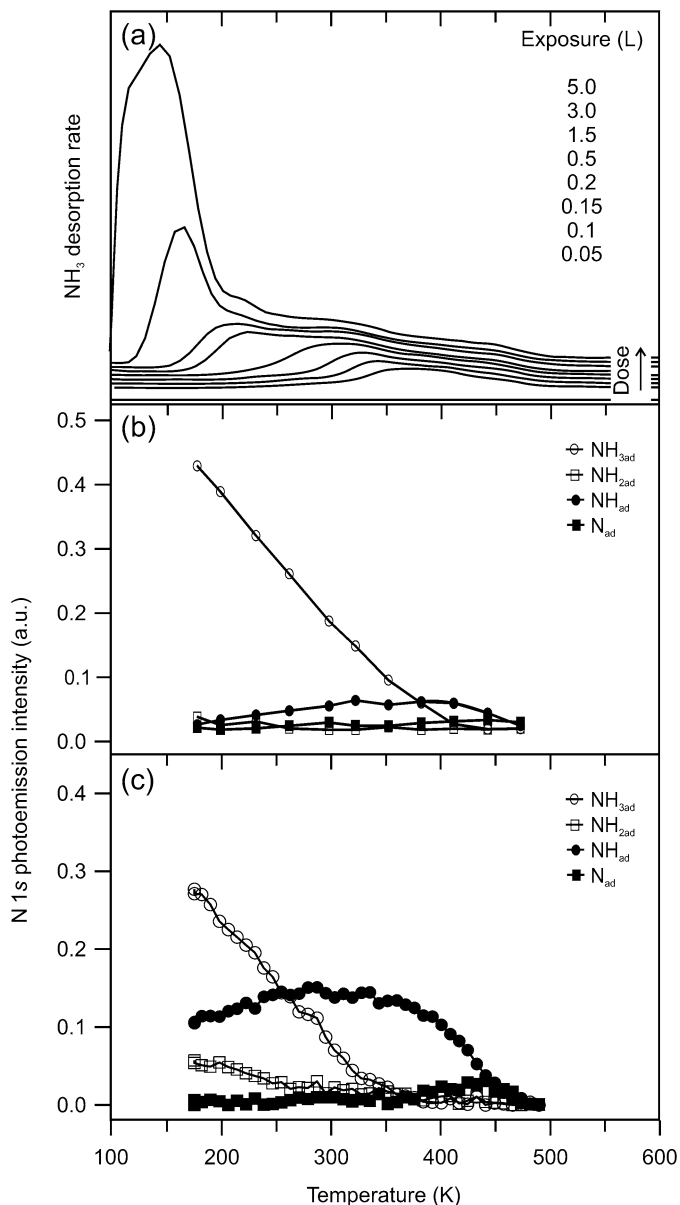


Fig. 1. (a)  $\text{NH}_3$  desorption after exposure to ammonia at 100 K ( $3 \text{ K s}^{-1}$ ). (b) TP-XPS results obtained during heating of an adsorbed  $\text{NH}_3$  layer ( $0.25 \text{ K s}^{-1}$ , exposed to  $\text{NH}_3$  at 175 K). The exposure to the X-rays was kept as low as possible. (c) Thermal behavior of  $\text{NH}_3$  dissociation products (formed by radiation damage) on Pt(410) ( $0.25 \text{ K s}^{-1}$ ).

The data presented in Fig. 1b differ drastically from that shown in Fig. 1c. In the experiment presented in panel (c), the surface was already exposed to radiation during exposure to  $\text{NH}_3$ , and it was also continuously exposed to the X-rays during heating. As a result, the concentration of dissociated species was high. For the experiment presented in Fig. 1b, the  $\text{NH}_3$  uptake was done in the absence of radiation, and during heating the number of data points was kept low, to minimize the radiation dose (each marker represents one data point,  $\sim 30 \text{ s}$ ). When the experiment was done in this way,  $\text{NH}_3$  dissociation was almost absent, in line with the TPD data. This shows that radiation has a profound effect on the surface chemistry of  $\text{NH}_{3\text{ad}}$ , and confirms that  $\text{NH}_3$  dissociation

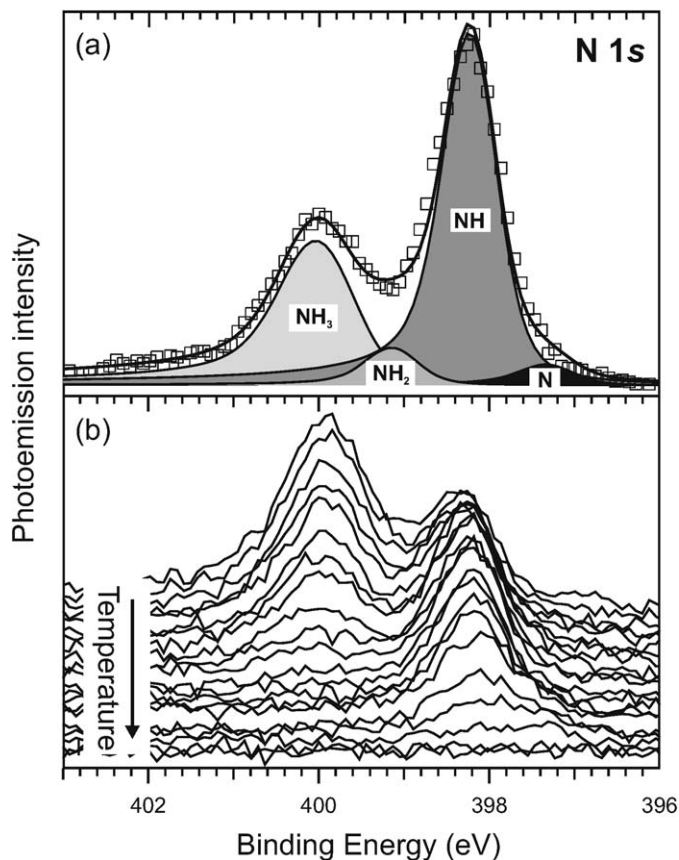


Fig. 2. (a) Components used to fit the N 1s spectra obtained during experiments with ammonia (average of three spectra). ( $\square$ ) Datapoints, (—) fit. (b) The actual spectra observed during heating ( $0.25 \text{ K s}^{-1}$ ) of an irradiated  $\text{NH}_{3\text{ad}}$  layer. Radiation damage causes the formation of  $\text{NH}_{x\text{ad}}$  ( $x = 0, 1, 2$ ).

Table 1  
Binding energies found for  $\text{NH}_3$ , NO and  $\text{O}_{\text{ad}}$  adsorption on Pt(410)<sup>a</sup>

Assignment	N 1s BE (eV)	O 1s BE (eV)
$\text{NH}_{3\text{ad}}$	400.0	—
$\text{NH}_{2\text{ad}}$	399.1	—
$\text{NH}_{\text{ad}}$	398.3	—
$\text{N}_{\text{ad}}$	397.4	—
$\text{NO}_{\text{ad}}$	400.7	533.0
$\text{O}_I$	—	530.8
$\text{O}_{II}$	—	531.7
$\text{O}_2$	—	532.4
$\text{H}_2\text{O}_{\text{ad}}$	—	534.2
$\text{CO}_{\text{ad}}$	—	534.1

<sup>a</sup> See Section 2 for more details about the calibration.

did not occur on the Pt(410) surface (in the absence of radiation).

### 3.2. Characterization of the oxygen-covered surface

Because no literature reports on  $\text{O}_2$  adsorption on Pt(410) are available, here we report a brief investigation of oxygen adsorption on Pt(410). Fig. 3 shows several O 1s core-level spectra of an oxygen-saturated ( $\text{O}_{2\text{ad}}/\text{O}_{\text{ad}}$ ) Pt(410) surface (10 L, 100 K), during both heating in vacuum [panels (b–d)] and heating in the presence of  $\text{H}_2$  [panel (a)]. Fig. 4 shows the thermal

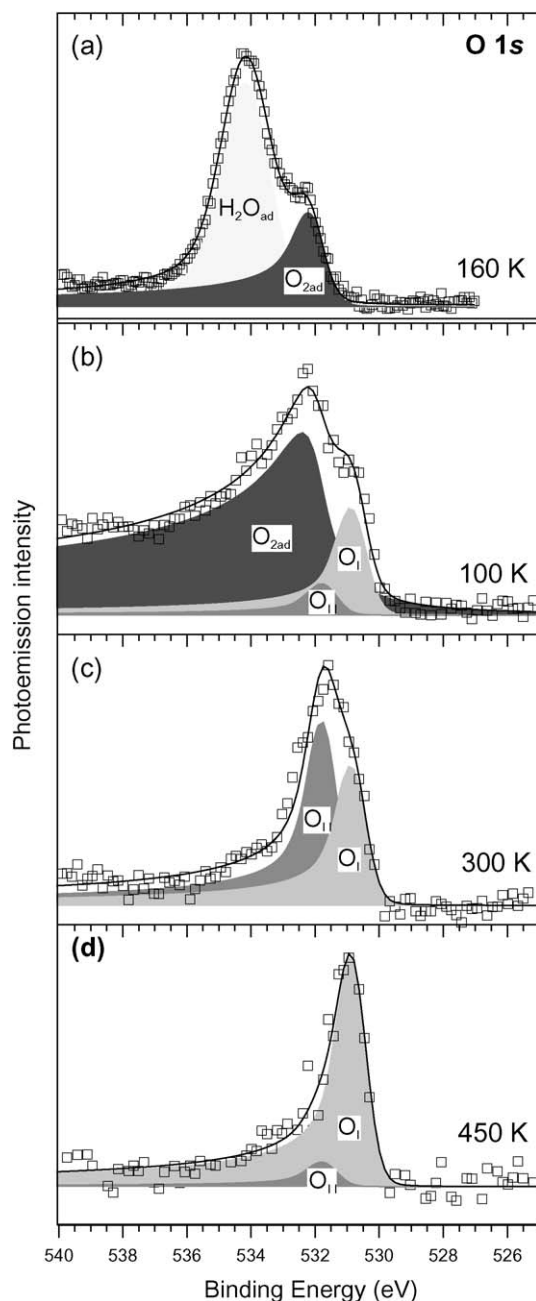


Fig. 3. XP-spectra taken during (a) heating of an adsorbed  $O_{2ad}/O_{ad}$  layer in the presence of  $H_2$  ( $0.25\text{ K s}^{-1}$ ,  $1 \times 10^{-7}$  mbar  $H_2$ ) and (b, c, d) during heating ( $0.25\text{ K s}^{-1}$ ) of a adsorbed  $O_{2ad}/O_{ad}$  layer in vacuum.

behavior of the different O 1s components in more detail. Panel (a) shows the thermal desorption of  $O_2$  during heating of an oxygen-saturated surface in vacuum, and panel (b) shows the corresponding TP-XPS results. The results shown in panel (c) were obtained during TP-XPS of an  $O_2$ -saturated surface in the presence of  $1 \times 10^{-7}$  mbar  $H_2$ .

Molecularly adsorbed  $O_2$  was stable only at low temperatures and was observed as a broad, asymmetric peak at 532.4 eV. During  $O_2$  uptake (not shown) at 100 K, both  $O_{ad}$  and  $O_2$  grew simultaneously.  $O_{2ad}$  desorbed/dissociated at around 150 K and was not observed above 200 K. Freyer et al. [28] reported the BEs for both  $O_{2ad}$  and  $O_{ad}$  on Pt(110)-(1 $\times$ 2).

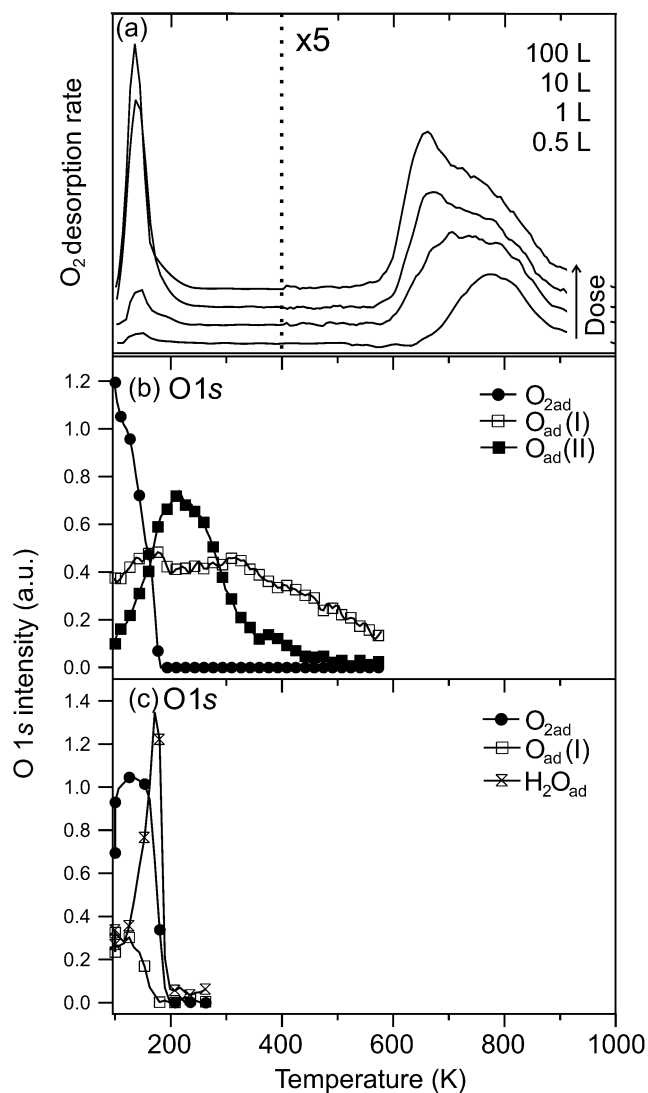


Fig. 4. (a) Oxygen desorption from Pt(410) after exposure to  $O_2$  at 100 K ( $3\text{ K s}^{-1}$ ). (b) Thermal behavior of different oxygen species during heating of an adsorbed  $O_{2ad}/O_{ad}$  layer in vacuum ( $0.25\text{ K s}^{-1}$ ) and (c) heating of an adsorbed  $O_{2ad}/O_{ad}$  layer in  $H_2$  ( $0.25\text{ K s}^{-1}$ ,  $1 \times 10^{-7}$  mbar  $H_2$ ).

$O_{2ad}$  was observed at 530.7 eV, whereas  $O_{ad}$  was observed at 529.9 eV. Their BEs do not exactly match the values that we obtained,<sup>1</sup> but the  $\Delta$ BE between  $O_{2ad}$  and  $O_{II}$  was  $\sim 0.8$  eV in both cases.

Above 200 K, two peaks can be distinguished, at 530.8 eV ( $O_I$ ) and 531.7 eV ( $O_{II}$ ), both of which are assigned to  $O_{ad}$ . The  $O_I$  species already formed at 100 K during exposure to  $O_2$ , whereas  $O_{II}$  was formed during  $O_{2ad}$  decomposition at around 150 K. During the slow heating ( $0.25\text{ K s}^{-1}$ ) used in the TP-XPS experiment,  $O_{II}$  was consumed via reaction with gases from the background ( $H_2$  and  $CO$ ), whereas  $O_I$  began to react when  $O_{II}$  was removed. This indicates that  $O_{II}$  is slightly more reactive than  $O_I$ .

The  $O_2$  thermal desorption spectra above 200 K (i.e., via  $O_{ad}$  combination) show two distinct high-temperature desorp-

<sup>1</sup> See Section 2 for details.



tion features, the first at around 670 K and the second at around 800 K. For thermal desorption from other stepped Pt surfaces, like (533) [29,30] two high-temperature O<sub>2</sub> desorption peaks were observed as well, whereas only a single high-temperature O<sub>2</sub> desorption peak was found for the low-index planes [31–33]. This suggests that the origin of the two desorption peaks is related to the presence of steps. It may be that these two distinct O<sub>2</sub> desorption peaks correspond to the two O<sub>ad</sub> species observed by XPS. The XPS measurements were limited to 600 K, and thus this assignment could not be validated.

During heating of an adsorbed O<sub>2ad</sub>/O<sub>ad</sub> layer in the presence of H<sub>2</sub>(g), an additional species was observed in the O 1s spectrum, between 100 and 200 K, with a BE of 534.2 eV. The fact that it appeared in the presence of H<sub>2</sub> (/H<sub>ad</sub>) suggests that it was either OH<sub>ad</sub> or H<sub>2</sub>O<sub>ad</sub>. The  $\Delta$ BE of 2.5 eV between this species and O<sub>II</sub> corresponded to the shift observed between O<sub>ad</sub> and H<sub>2</sub>O<sub>ad</sub> on Pt(111) [34,35]. Kiskinova et al. [36] reported a 1-eV shift between O<sub>ad</sub> and OH<sub>ad</sub> on Pt(111). In contrast, EELS experiments on Pt(111) [3] indicated that OH<sub>ad</sub> formed during NH<sub>3ad</sub> dehydrogenation and that was stable up to 285 K, so this is another possibility. We tentatively assign this peak to H<sub>2</sub>O<sub>ad</sub> on the basis of the BE, but we cannot exclude the possibility that it was OH<sub>ad</sub> rather than H<sub>2</sub>O<sub>ad</sub>.

### 3.3. The effect of O<sub>ad</sub> on the NH<sub>3</sub> surface chemistry

Fig. 5 shows the results obtained during heating of an oxygen-saturated surface (10 L at 200 K), postdosed with NH<sub>3</sub> (3 L). Panel (a) shows the gas-phase products observed during heating (3 K s<sup>-1</sup>). Molecular NH<sub>3</sub> desorption was found between 110 and 450 K, with a peak at around 150 K (second NH<sub>3</sub> layer) and a broad desorption region between 150 and 450 K. H<sub>2</sub>O desorption occurred between 200 and 350 K. A small amount of N<sub>2</sub> formation (observed for both  $m/e = 28$  and 14) was already found at around 200 K, but the largest part of the N<sub>2</sub> desorption was observed between 350 and 500 K. NO formation was not observed in this particular experiment. The conditions under which it forms are discussed in Section 3.4. Similar experiments have been performed by Mieher and Ho [3] for Pt(111), who found N<sub>2</sub> desorption between 400 and 600 K on Pt(111), somewhat higher than in our experiment, in which a part of the N<sub>2</sub> desorption occurs already at around 200 K, and above 500 K N<sub>2</sub> desorption was no longer observed; that is, N<sub>2</sub> desorption (via N<sub>ad</sub> combination) occurred at a lower temperature on Pt(410).

Figs. 5c and 5d show the TP-XPS results obtained during a similar experiment. We took great care to avoid beam damage during the experiments and checked the influence of the radiation on the outcome of the experiments. The effect of the radiation was negligible in the results presented here. For the N 1s spectra, we dosed NH<sub>3</sub> at 175 K, to avoid the formation of either a second NH<sub>3</sub> layer or NH<sub>3</sub> ice, which can obscure the N 1s spectra [13]. For the O 1s spectra, we dosed NH<sub>3</sub> at 100 K, and in this experiment the second NH<sub>3</sub> layer was formed. Desorption of this layer, which partly blocks the signal from the O<sub>ad</sub> layer underneath, explains the increase in the O<sub>ad</sub> signal between 100 and 150 K. Starting at 100 K allowed

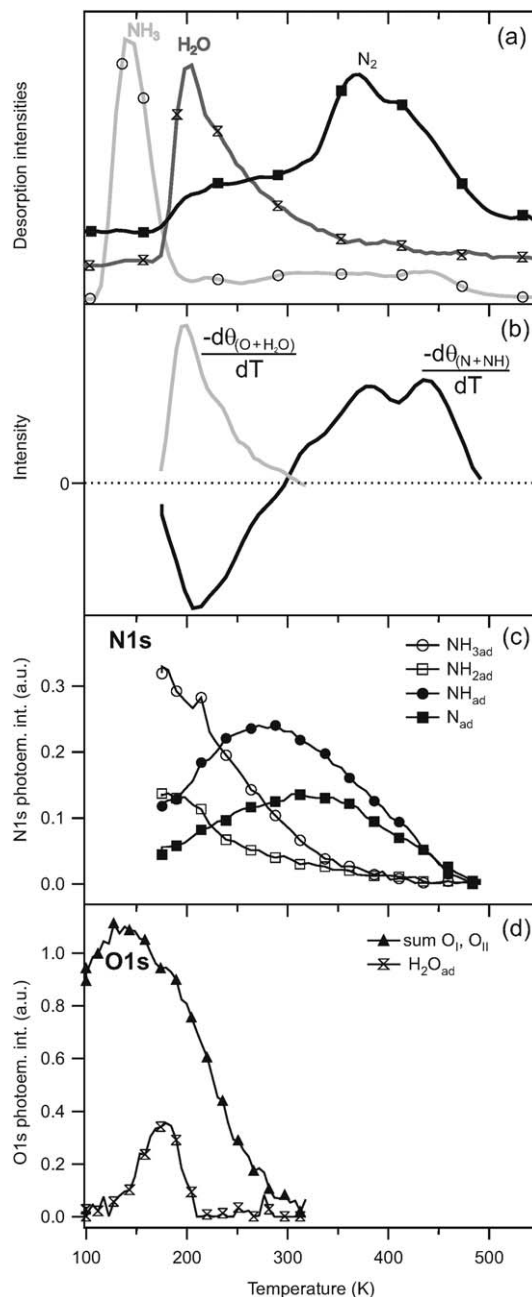


Fig. 5. (a) NH<sub>3</sub>, H<sub>2</sub>O and N<sub>2</sub> desorption observed during heating of a co-adsorbed NH<sub>3ad</sub>/O<sub>ad</sub> layer (3 K s<sup>-1</sup>). (b) The derivative of the XPS data (similar to thermal desorption spectra). (c) Intensities of the different N 1s components obtained during heating of a co-adsorbed NH<sub>3ad</sub>/O<sub>ad</sub> layer (0.25 K s<sup>-1</sup>). (d) Intensities of the different O 1s components obtained during heating of a co-adsorbed layer (0.25 K s<sup>-1</sup>).

us to observe the onset of H<sub>2</sub>O<sub>ad</sub> formation and thus the onset of NH<sub>3ad</sub> dehydrogenation, which was found to occur already around 150 K. About 40% of the O<sub>ad</sub> initially present formed H<sub>2</sub>O<sub>ad</sub> below 200 K, whereas the remaining 60% reacted between 200 and 300 K, forming H<sub>2</sub>O(g). We did not observe OH<sub>ad</sub> formation, but this is not surprising, because calculations performed by Offermans et al. [Pt(111)] showed [37], that OH<sub>ad</sub> species are more reactive than O<sub>ad</sub> and immediately react with NH<sub>xad</sub> species to form H<sub>2</sub>O<sub>ad</sub>. In the N 1s spectra several NH<sub>xad</sub> species were already present at the start of the experi-

ment at 175 K (because the reaction between  $O_{ad}$  and  $NH_{3ad}$  already occurred at around 150 K).

The  $NH_{3ad}$  concentration was found to decrease between 175 and 400 K, due to both decomposition and desorption. The  $NH_{2ad}$  concentration also decreased between 150 and 250 K, and its concentration was very low above 300 K. Both the  $N_{ad}$  and  $NH_{ad}$  concentrations increased between 175 and 300 K (due to  $NH_{3ad}$  and  $NH_{2ad}$  decomposition) and decreased again above 300 K ( $NH_{ad}$  dehydrogenated to  $N_{ad}$ , which desorbed as  $N_2$ ). Because both  $N_{ad}$  and  $NH_{ad}$  were present at the  $N_2$  desorption temperature, we cannot exclude the possibility that  $N_2$  formation involves  $N_2H_x$  species.

The presence of  $NH_{ad}$  above 300 K, after all of the  $O_{ad}$  was consumed, seems to contradict the thermal desorption data. Decomposition of this  $NH_{ad}$  (in the absence of  $O_{ad}$ ) should result in the formation of  $H_2$ , but this was not observed in the TPD experiment. However, during heating of an  $O_{ad}$  layer in vacuum, we found (see Section 3.2) that  $O_{ad}$  was slowly removed by reaction with  $H_2$  and CO from the residual gas. Due to the low heating rate ( $0.25\text{ K s}^{-1}$ ) used in the TP-XPS, much  $O_{ad}$  will be removed in this way, leaving less  $O_{ad}$  available to react with the remaining  $NH_{ad}$ . In the TPD experiment, the heating rate was about 10 times higher (i.e.,  $3\text{ K s}^{-1}$ ), and thus  $O_{ad}$  removal by reaction with residual gases played only a minor role.

The XPS results can be used to calculate the thermal desorption spectra. The TPD signal corresponds to  $-d\theta/dT$ , and by differentiating the  $\theta(T)$  signals found with XPS, the thermal desorption spectra can be “calculated.” This is a useful method for comparing the TP-XPS and TPD results. The differentiated  $\theta_{O+H_2O}$  signal [Fig. 5b] was found to be very similar to the  $H_2O$  formation observed in the gas phase. This shows that the results found for TPD and TP-XPS are very similar, even though the experimental conditions were different (i.e., different heating rates). The differentiated  $(\theta_{NH} + \theta_N)$  signal below 300 K shows that  $NH_{ad}$  and  $N_{ad}$  formed at the same temperature as  $H_2O(g)$ , whereas the differentiated  $(\theta_{NH} + \theta_N)$  signal above 300 K matches the  $N_2$  desorption observed in the gas phase; that is, the  $N_2$  desorption peak was a result of desorption of  $N_{ad}$  (and decomposition of  $NH_{ad}$ ) already present on the surface at 300 K.

### 3.4. $N_2$ vs. NO formation

A recent publication [12] discussed the surface chemistry of NO on Pt(410). In the N 1s spectra, two types of NO, with N 1s BEs of 400.7 and 401.3 eV, were observed. In the O 1s spectra, only one species was observed, at 533.0 eV. In some of the experiments with ammonia and oxygen, the formation of  $NO_{ad}$  was also observed. The peak due to  $NO_{ad}$  appeared at 400.7 eV in the N 1s region and at 533 eV in the O 1s region.

Mieher and Ho [3] showed that NO formation on Pt(111) depends strongly on the amount of available  $O_{ad}$  compared with the amount of  $NH_{3ad}$  present. They reported the formation of  $NO(g)$ , but only when the surface was precovered with a large amount of  $O_{ad}$  and subsequently exposed to a relatively small amount of  $NH_3$ . This observation was rationalized by the following mechanism: Most  $O_{ad}$  is consumed during  $NH_{3ad}$

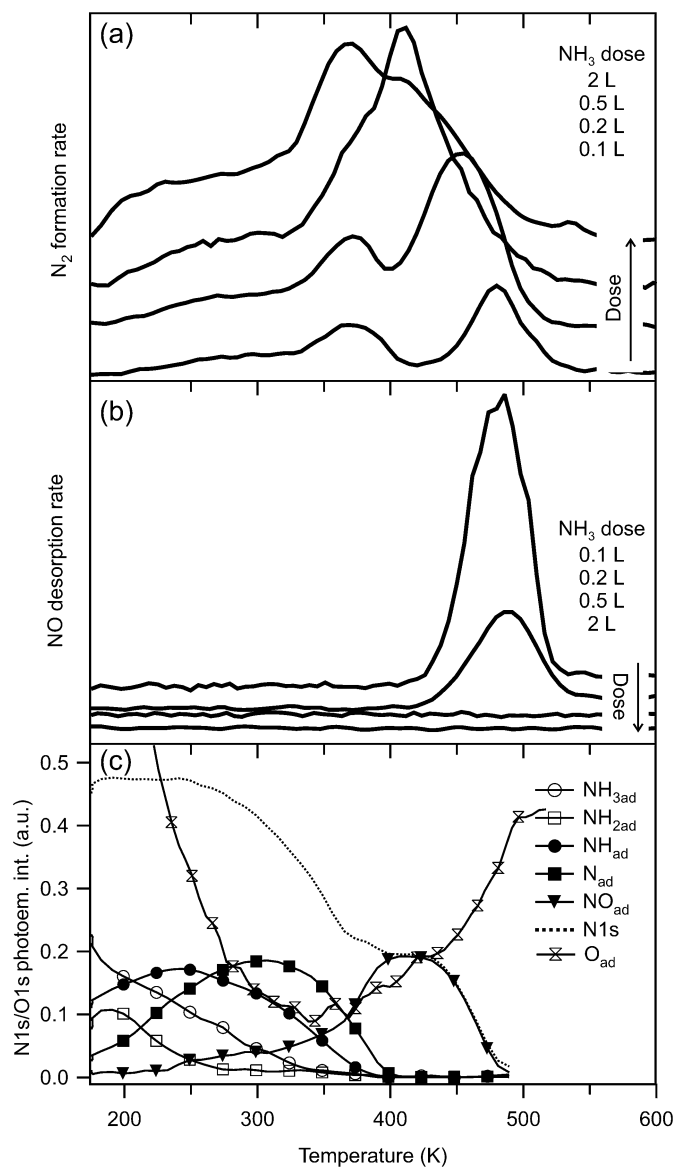


Fig. 6. (a)  $N_2$  formation during heating of an  $O_{ad}$  saturated surface (10 L) after different  $NH_3$  post-exposures ( $3\text{ K s}^{-1}$ ). (b) NO formation during heating of an  $O_{ad}$  saturated surface (10 L) after different  $NH_3$  post-exposures ( $3\text{ K s}^{-1}$ ). (c) N 1s and O 1s components during heating of a co-adsorbed  $NH_{3ad}/O_{ad}$  layer ( $0.25\text{ K s}^{-1}$ ) in the presence of  $5 \times 10^{-8}$  mbar  $O_2$ . The  $O_{ad}$  signal shown is the sum of  $O_I$  and  $O_{II}$ .

dehydrogenation (forming  $H_2O$ ), and NO can be formed only when  $O_{ad}$  remains after  $NH_{xad}$  dehydrogenation, that is, when the amount of  $NH_{3ad}$  is small compared with the amount of  $O_{ad}$ .

A similar trend was observed on Pt(410). Figs. 6a and 6b show both  $N_2$  and NO desorption after exposure of an oxygen-saturated surface (10 L at 200 K) to different amounts of  $NH_3$ . Similar to Pt(111), NO desorption occurred only after small doses of ammonia (0.1–0.2 L).  $N_2$  formation observed in a TPD experiment after these low  $NH_3$  doses shows two maxima at around 350 and 450 K. We suggest that these different peaks originated from two different mechanisms. The oxygen remaining on the surface after  $NH_{3ad}$  dehydrogenation reacted with  $N_{ad}$  to form  $NO_{ad}$  between 200 and 400 K. The  $N_{ad}$  that did not react with  $O_{ad}$  desorbed as  $N_2$  at around 350 K. This ex-

plains the first N<sub>2</sub> desorption peak. NO<sub>ad</sub> decomposition started at above 400 K [12], and the N<sub>ad</sub> formed in this process desorbed as N<sub>2</sub> at around 450 K, the second N<sub>2</sub> desorption peak. A similar reaction scheme was proposed by Bradley et al. [11] for Pt(100).

This specific experiment was difficult to reproduce during the TP-XPS measurements (due to reaction of O<sub>ad</sub> with background gases); thus, a different approach was adopted. An O<sub>2</sub> uptake experiment (not shown) on a NH<sub>3ad</sub>-saturated surface (at 175 K) revealed that O<sub>2</sub> could access the surface and dissociate, even in the presence of a saturated NH<sub>3ad</sub> layer. We drew on this finding in an attempt to make NO<sub>ad</sub>. In this particular experiment, a mixed O<sub>ad</sub>/NH<sub>3ad</sub> layer was heated in the presence of  $5 \times 10^{-8}$  mbar O<sub>2</sub>. Here O<sub>2</sub> could replenish the O<sub>ad</sub> consumed during NH<sub>xad</sub> dehydrogenation, and as a result O<sub>ad</sub> was present throughout the experiment. Fig. 6c shows the results of this experiment, as observed with XPS.

Comparing these results with those of a similar experiment in the absence of O<sub>2</sub>(g) but in the presence of O<sub>ad</sub> (see Fig. 5) reveals several differences. The NH<sub>ad</sub> concentration decreased at a lower temperature in the presence of O<sub>2</sub>(g), due to the fact that in this experiment more O<sub>ad</sub> was available and NH<sub>ad</sub> could be completely dehydrogenated via reaction with O<sub>ad</sub>. The formation of NO<sub>ad</sub> was observed only in the presence of O<sub>2</sub>(g). This finding is in line with the model presented in the previous paragraphs; that is, NO<sub>ad</sub> could form only when O<sub>ad</sub> was available after all NH<sub>xad</sub> was dehydrogenated.

The differentiated total N 1s signal ( $\theta_{\text{NH}_x} + \theta_{\text{N}} + \theta_{\text{NO}}$ , not shown) corresponds rather well to the TPD results obtained using a low NH<sub>3</sub> postexposure; the decreased N 1s intensity between 300 and 350 K corresponds to the first N<sub>2</sub> desorption peak. A part of the N<sub>ad</sub> formed NO<sub>ad</sub>, which desorbed/decomposed between 400 and 500 K. NO<sub>ad</sub> can be clearly observed in both the N 1s and O 1s region above 400 K, where it was the only species (next to O<sub>ad</sub>) present. Below 400 K, determining the exact intensity of the NO<sub>ad</sub> peak is more difficult, due to the fact that other species (especially NH<sub>3ad</sub>) overlapped with the NO<sub>ad</sub> peak. Therefore, the exact temperature at which NO<sub>ad</sub> formation started cannot be determined. From spectra obtained during steady-state NH<sub>3</sub> oxidation (see Section 3.5), we tentatively conclude that NO<sub>ad</sub> formation started already at around 200 K. Reflection absorption infrared spectroscopy (RAIRS) experiments done by Kim et al. [38] showed that NO<sub>ad</sub> formation on Pt(100) started at around 275 K.

From the XPS data, we cannot distinguish NO<sub>ad</sub> decomposition from NO<sub>ad</sub> desorption, because N<sub>ad</sub> formed during dissociation immediately desorbed as N<sub>2</sub> and was not observed on the surface. The fact that the NO<sub>ad</sub> concentration dropped at around 450 K and *not* at around 400 K, the temperature at which NO<sub>ad</sub> decomposition started (see Ref. [12]), indicates that NO<sub>ad</sub> desorbed rather than decomposed. Experiments done by Bradley et al. on Pt(100) indicated that a high O<sub>ad</sub> concentration inhibited NO<sub>ad</sub> dissociation [11]. In our experiment, we found a rather high O<sub>ad</sub> concentration at around 450 K, so it is very well possible that it blocked NO<sub>ad</sub> dissociation and that the decreased NO<sub>ad</sub> was due to desorption rather than to dissociation.

### 3.5. Steady-state NH<sub>3</sub> oxidation on Pt(410)

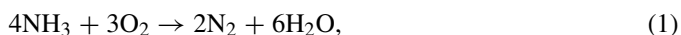
Fig. 7 shows the results obtained during steady-state NH<sub>3</sub> oxidation (ratio 1:1). Panels (a) and (b) show the gas-phase products, and panels (c) and (d) and (e) and (f) show the N 1s and O 1s components, respectively. Both the results obtained during heating [(a), (c), and (e)] and during subsequent cooling [(b), (d), and (f)] are shown. The surface was saturated with O<sub>ad</sub> (10 L O<sub>2</sub>, 200 K) before being exposed to the reaction mixture.

At 250 K, the surface was covered with a mixture of NH<sub>3ad</sub> (+NH<sub>2ad</sub>), NH<sub>ad</sub>, N<sub>ad</sub>, and NO<sub>ad</sub>. The concentrations of NH<sub>3ad</sub> (+NH<sub>2ad</sub>), NH<sub>ad</sub>, and N<sub>ad</sub> decreased with increasing temperature. The adsorption of O<sub>2</sub> from the gas phase seemed to be hindered by the NH<sub>xad</sub> species present on the surface, and all O<sub>ad</sub> that formed on the surface immediately reacted with NH<sub>xad</sub> species. This explains why the O<sub>ad</sub> concentration remained low.

NO<sub>ad</sub> formation was already observed around 250 K. In the N 1s spectrum, the peak due to NO<sub>ad</sub> was not very well resolved, due to the presence of several other N-containing species (especially NH<sub>3ad</sub>), but it was clearly observed in the O 1s spectra, being the only peak present at this temperature. The amount of NO<sub>ad</sub> did not change between 200 and 400 K, but above 400 K, NO decomposition started (because no O<sub>ad</sub> was present, which would otherwise inhibit NO<sub>ad</sub> decomposition). As a result, the NO<sub>ad</sub> concentration dropped. It is important to note that only a part of the N<sub>ad</sub> formed NO<sub>ad</sub>, whereas an equal part did not react and was present as N<sub>ad</sub>.

In the gas phase, both H<sub>2</sub>O and N<sub>2</sub> formation were observed between 400 and 600 K. The N-selectivity of the reaction changed above 600 K from N<sub>2</sub>(g) to NO(g). The surface was almost empty at this temperature; that is, the NH<sub>xad</sub>, NO<sub>ad</sub>, and O<sub>ad</sub> concentrations were almost zero. Due to experimental limitations, we were not able to observe the surface coverage above this temperature.

The change in N-selectivity was accompanied by a decrease in H<sub>2</sub>O(g) formation. According to the overall reaction equations (1) and (2), more oxygen is needed for the formation of NO and H<sub>2</sub>O than for formation of N<sub>2</sub> and H<sub>2</sub>O. The ratio of 1:1 used in this experiment means that only a relatively small amount of oxygen was available, too little to oxidize all of the NH<sub>3</sub> to NO. As a result, the NH<sub>3</sub> conversion dropped above 600 K. In other words, the reaction rate during NO + H<sub>2</sub>O formation decreased due to a lack of oxygen:



The cooling branch provides a better source of information about the steady-state reaction, because non-steady-state effects, caused by desorption of adsorbates present at low temperature, are absent. Above 400 K, the reaction, as observed by the gas-phase products, proceeded in the same manner, and all essential features, including reaction rate, selectivity change (around 600 K), and starting/stopping of the reaction (around 400 K), were similar for the heating and cooling branches.

The surface composition as a function of temperature was slightly different in the cooling branch, specifically below

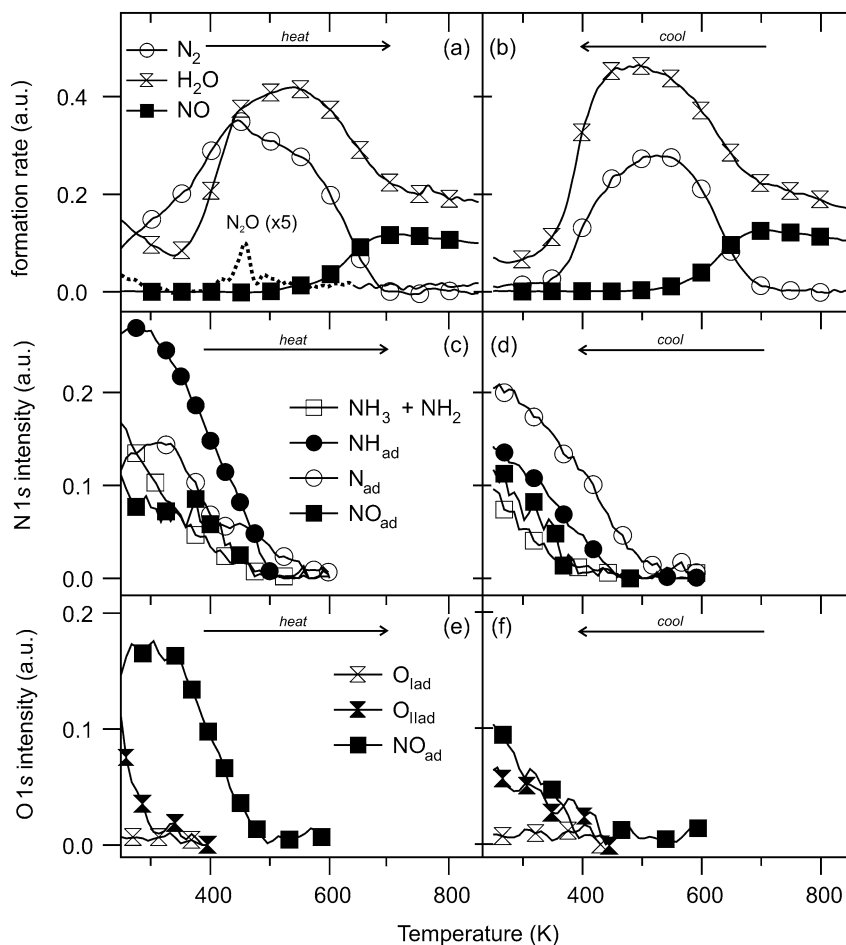


Fig. 7. Gas phase products (a, b) and surface coverage (c–f) during  $\text{NH}_3$  oxidation on Pt(410), using a  $\text{NH}_3/\text{O}_2$  ratio of 1:1. The heating and cooling branch are both shown ( $p_{\text{NH}_3} = 1 \times 10^{-7}$  mbar (TPR)/ $5 \times 10^{-8}$  mbar (XPS),  $\text{NH}_3:\text{O}_2 = 1:1$ , heating rate  $0.5 \text{ K s}^{-1}$  (TPR)/ $0.25 \text{ K s}^{-1}$  (XPS)), 1 data point per  $\sim 10$  K.

$\sim 500$  K. The surface began to be covered by  $\text{N}_{\text{ad}}$  in the cooling branch, followed by  $\text{NH}_{\text{ad}}$ ; at even lower temperatures, both  $\text{NH}_{3\text{ad}}$  (+ $\text{NH}_{2\text{ad}}$ ) and  $\text{NO}_{\text{ad}}$  were observed. The amount of  $\text{N}_{\text{ad}}$  present in the cooling branch was larger than that in the heating branch, whereas the  $\text{NH}_{\text{ad}}$  and  $\text{NH}_{3\text{ad}}$  coverages were lower.

### 3.5.1. The influence of the reactant ratio

We also studied the effect of  $\text{O}_2$  partial pressure on the reaction rate and selectivity. The results presented in Fig. 8 were obtained using an  $\text{NH}_3/\text{O}_2$  ratio of 1:5, i.e., an excess of  $\text{O}_2$ . The  $\text{NH}_3$  pressure was similar to the pressure used for the ratio 1:1, and the  $\text{O}_2$  pressure was adjusted according to the desired ratio. The surface was precovered with  $\text{O}_{\text{ad}}$  before the reaction mixture was admitted.

The nature and abundance of the gas-phase products observed below  $\sim 400$  K in the first heating branch were the result of a complex combination of desorption of the initially present surface species and the products of steady-state reaction.  $\text{N}_2$  formation showed two distinct peaks, one around 380 K and another one around 450 K.  $\text{H}_2\text{O}$  formation started at around 350 K, a similar temperature as for a reactant ratio of 1:1. The amount of water formed provides a good measure of the reaction rates for the two different ratios. For both ratios, the maximum  $\text{H}_2\text{O}$  formation occurred at around 500 K, and

the amount of  $\text{H}_2\text{O}$  formation (i.e., the reaction rate) was about 1.5 times higher for the 1:5 ratio than for the 1:1 ratio. The greatest difference between the two ratios was the temperature at which the change in the N-selectivity occurred. For a ratio of 1:1, the selectivity changed at around 600 K, whereas for a ratio of 1:5, the selectivity changed at around 450 K. Because of the large amount of  $\text{O}_2$  present, the  $\text{H}_2\text{O}$  formation for a ratio of 1:5 was not influenced by the selectivity change, in contrast to what we observed for a ratio of 1:1. Above 800 K, the reaction rate dropped. This is explained by the fact that  $\text{O}_{\text{ad}}$  starts to desorb (as  $\text{O}_2$ ) (see Section 3.2), resulting in a lower  $\text{O}_{\text{ad}}$  concentration, and thus a lower reaction rate. A small peak was also observed for  $m/e = 44$  between 400 and 500 K, somewhat higher than the  $m/e = 44$  desorption peak found for a ratio of 1:1. We tentatively assign this peak to  $\text{N}_2\text{O}$  formed via reaction between  $\text{N}_{\text{ad}}$  and  $\text{NO}_{\text{ad}}$ .

In the cooling branch, only the products of the steady-state reaction were observed. During cooling,  $\text{N}_2$  formation showed only a single peak, at around 420 K. The  $\text{N}_2$  desorption peak observed at around 380 K in the heating branch is therefore assigned to a transient desorption peak, due to desorption of  $\text{N}_{\text{ad}}$  already present on the surface at lower temperature.

The results of the XPS measurements are shown in Figs. 8c–8f. The thermal behavior of the different  $\text{NH}_{x\text{ad}}$  species was



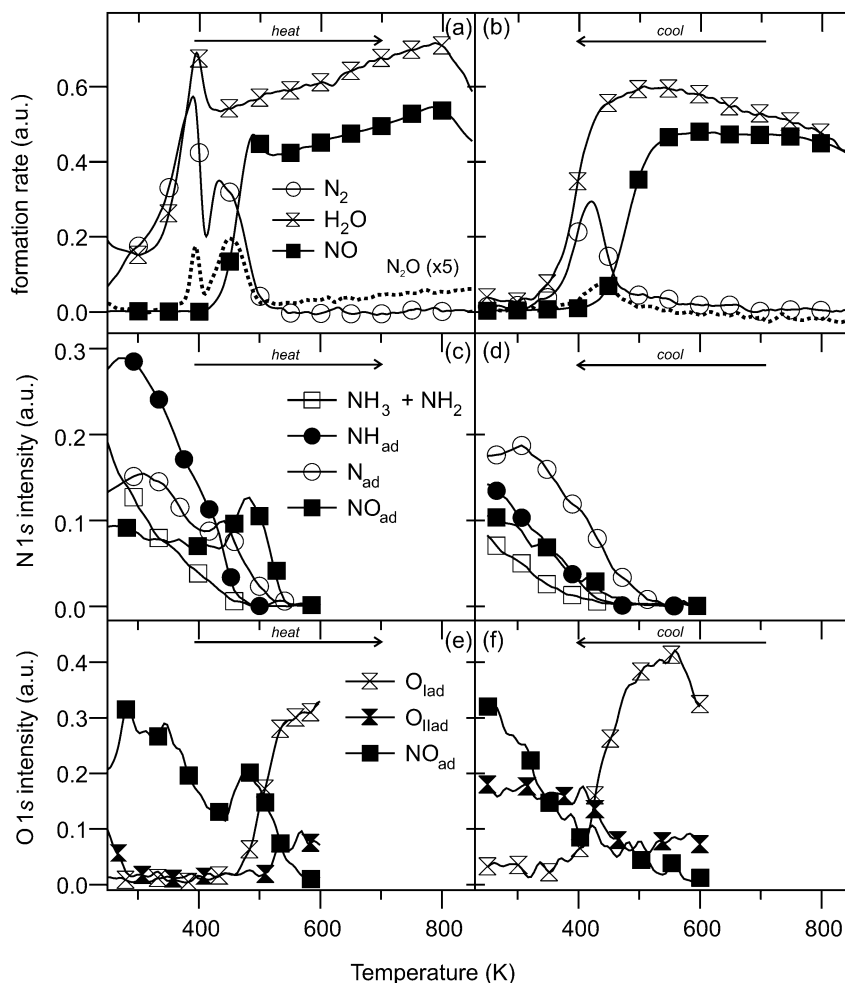


Fig. 8. Gas phase products (a, b) and surface coverage (c–f) during  $\text{NH}_3$  oxidation on Pt(410), using a  $\text{NH}_3/\text{O}_2$  ratio of 1:5. The heating and cooling branch are both shown (TPR:  $0.5 \text{ K s}^{-1}$ ,  $1 \times 10^{-7} \text{ mbar NH}_3$ , TP-XPS:  $0.25 \text{ K s}^{-1}$ ,  $5 \times 10^{-8} \text{ mbar NH}_3$ , 1 data point per  $\sim 10 \text{ K}$ ).

very similar for both  $\text{NH}_3/\text{O}_2$  ratios (1:1 and 1:5), whereas the  $\text{NO}_{\text{ad}}$  concentration was rather different for both ratios. For the ratio 1:5,  $\text{NO}_{\text{ad}}$  was present between 200 and 450 K; at 450 K, its concentration increased, reaching a maximum at around 480 K. For higher temperatures, the  $\text{NO}_{\text{ad}}$  concentration decreased again.  $\text{NO}_{\text{ad}}$  dissociation did not occur when a ratio of 1:5 was used, because  $\text{O}_{\text{ad}}$  was present on the surface above  $\sim 450 \text{ K}$ , and it inhibited  $\text{NO}_{\text{ad}}$  dissociation.

The O 1s spectral region shows a large difference between the two ratios. For the 1:5 ratio, the surface became  $\text{O}_{\text{ad}}$ -covered at around 450 K, in contrast to what was found for a 1:1 ratio. The change in surface coverage (from  $\text{NH}_{\text{xad}}/\text{N}_{\text{ad}}$ -to  $\text{O}_{\text{ad}}$ -covered) found for the 1:5 ratio coincides with the N-selectivity change in the gas phase. This shows that the selectivity of the  $\text{NH}_3$  oxidation reaction on Pt(410) was determined by the surface coverage; when the surface was  $\text{NH}_{\text{xad}}/\text{N}_{\text{ad}}$ -covered, the reaction product was mainly  $\text{N}_2$ , but when the surface was  $\text{O}_{\text{ad}}$ -covered, NO was the major product. The small amount of  $\text{N}_2\text{O}$  observed was formed only when both  $\text{N}_{\text{ad}}$  and  $\text{NO}_{\text{ad}}$  coexisted on the surface. This suggests that it formed via a reaction between  $\text{N}_{\text{ad}}$  and  $\text{NO}_{\text{ad}}$ .

The nature and concentration of the surface species in the cooling branch also differed from that in the heating branch.

A hysteresis was observed in the  $\text{O}_{\text{ad}}$  concentration; that is,  $\text{O}_{\text{ad}}$  was observed on the surface down to 400 K, whereas in the heating branch  $\text{O}_{\text{ad}}$  was observed only above 500 K. This also influenced the  $\text{NH}_{\text{xad}}$  chemistry; more  $\text{N}_{\text{ad}}$  than  $\text{NH}_{\text{ad}}$  was present on the surface in the cooling branch.

#### 4. General discussion

Thermal desorption spectra of  $\text{NH}_3$  co-adsorbed with  $\text{O}_{\text{ad}}$  showed some  $\text{N}_2(\text{g})$  formation already around 200 K, similar to the low-temperature  $\text{N}_2$  desorption peak observed for Pt(100) [11] but significantly less than  $\text{N}_2$  desorption from Pt(111) ( $>400 \text{ K}$ ), as observed by Mieher and Ho [3]. A similar trend was observed for  $\text{NO}_{\text{ad}}$  formation. Kim et al. found that  $\text{NO}_{\text{ad}}$  formation started at around 300 K on Pt(100). We found that  $\text{NO}_{\text{ad}}$  formation started at between 200 and 300 K on Pt(410). On Pt(111), on the other hand, the formation of  $\text{NO}_{\text{ad}}$  was not detected at all by EELS, whereas  $\text{NO}(\text{g})$  was observed above 400 K [3]. These results indicate a special reactivity of the {100} facets of Pt, for several elementary steps in the  $\text{NH}_3$  oxidation mechanism. Recent density functional theory (DFT) calculations [39,40] indicated that the activation energies for  $\text{N}_{\text{ad}}$  combination and  $\text{NO}_{\text{ad}}$  formation were much lower

on (bulk-terminated) Pt(100) and Pt(410) ( $\sim 90$  and  $\sim 70$  meV per molecule, respectively) than on other Pt surfaces. Therefore, we explain the low-temperature  $\text{N}_2$  desorption and the low-temperature  $\text{NO}_{\text{ad}}$  formation by the fact that the activation barriers associated with these processes are much lower on Pt(410) than on, for example, Pt(111).

Several authors have investigated steady-state  $\text{NH}_3$  oxidation on stepped Pt single crystal surfaces, including Pt(533) [4-atom-wide {111} terraces, {100} steps], Pt(443) [7-atom-wide {111} terraces, {111} steps] and Pt(S)-12(111) $\times$ (111) [2,41,42]. The general trend found for all these surfaces is that  $\text{N}_2 + \text{H}_2\text{O}$  forms at low temperatures, whereas  $\text{NO} + \text{H}_2\text{O}$  forms at high temperatures. The exact temperature at which the N-selectivity changes varies for the different surfaces. Comparison between the different surfaces is complicated by the fact that the experimental conditions vary significantly. Scheibe et al. studied both Pt(533) and Pt(443), using similar reaction conditions for both surfaces and concluded that Pt(533) is more active than Pt(443). They offered two explanations for this difference: (i) the step density is higher for Pt(533) or (ii) the nature of the steps is different; that is, the {100} steps on Pt(533) are particularly reactive. In view of the preceding discussion, we support the second model.

In 2003, Günther et al. [43] published a *high-pressure* ( $\sim$  mbar) XPS study of ammonia oxidation on Pt(533) [{111} terraces, {100} steps]. They reported several peaks in the N 1s region, very similar to the peaks that we found on Pt(410). They also found that the  $\text{NH}_{\text{xad}}$  chemistry on the surface was similar at both low and high reactant pressures. These results show that low-pressure studies like ours are also relevant for understanding catalysis at industrially relevant pressures.

In a recent publication, we reported our results on  $\text{NH}_3$  oxidation on Ir(110) and Ir(111) [9,13,14]. On Ir(110), we found that the change of surface composition from  $\text{N}_{\text{ad}}$ -covered to  $\text{O}_{\text{ad}}$ -covered occurred at significantly lower temperatures ( $\Delta T \sim 200$  K) than the change in gas-phase selectivity. This was explained by a difference between the activation energies between  $\text{N}_2$  formation and NO formation on Ir(110). On Pt(410), we showed that the change in surface coverage correlates with the change in gas-phase selectivity. Therefore, in the case of Pt(410), the gas-phase selectivity is governed by the surface coverage rather than by any difference in activation energy.

These kinetic considerations cannot be extended directly to other Ir and Pt facets, because the surfaces used in this case both demonstrate some *special* behavior. The activation barriers associated with  $\text{N}_2$  and NO formation are much lower on Pt(410) than on other Pt surfaces, which should be kept in mind when applying insights obtained on surfaces containing {100} facets [like Pt(100), Pt(410), and Pt(533)] to other surfaces. On Ir(110), the presence of  $\text{O}_{\text{ad}}$  has a large effect on the  $\text{N}_2$  formation rate [44].

Thermodynamic considerations offer a different, more general explanation for the different selectivities for Pt and Ir catalysts. These considerations are based on literature data regarding the (111) surfaces of Pt and Ir. Both  $\text{O}_{\text{ad}}$  desorption (as  $\text{O}_2$ ) and  $\text{N}_{\text{ad}}$  desorption (as  $\text{N}_2$ ) occur at a higher temperature (+300 K for  $\text{O}_{\text{ad}}$  and +50 K for  $\text{N}_{\text{ad}}$ ) from Ir(111) than from

Pt(111) [14,45–47], whereas NO desorption occurs at around the same temperature on both surfaces [45,48]. On Pt surfaces,  $\text{NO}_{\text{ad}}$  formation from  $\text{N}_{\text{ad}}$  and  $\text{O}_{\text{ad}}$  was found to be exothermic [39,40], which is the driving force for  $\text{NO}_{\text{ad}}$  formation on Pt. Ir(111) interacts more strongly with the atomic adsorbates (as shown by the higher  $\text{N}_2$  and  $\text{O}_2$  desorption temperatures), implying that  $\text{NO}_{\text{ad}}$  formation is less exothermic on Ir(111) than on Pt(111). As a result Ir(111) is less active for NO formation (and more active for NO dissociation) than Pt(111).

## 5. Conclusion

This study has investigated several elementary steps occurring during  $\text{NH}_3$  oxidation on Pt(410). Ammonia adsorbs molecularly on Pt(410) and desorbs between 200 and 450 K. Radiation can induce dissociation, and several  $\text{NH}_{\text{xad}}$  surface species have been observed.  $\text{NH}_{\text{ad}}$  was found to be the most abundant (and probably most stable) surface species; it dissociates above 350 K. The  $\text{N}_{\text{ad}}$  (and  $\text{H}_{\text{ad}}$ ) formed immediately desorb as  $\text{N}_2$  (and  $\text{H}_2$ ).

$\text{O}_2$  adsorbs both molecularly and dissociatively on Pt(410). Heating of an adsorbed  $\text{O}_2/\text{O}_{\text{ad}}$  layer results in  $\text{O}_2$  desorption at around 160 K. The atomic oxygen desorbs (as  $\text{O}_2$ ) in two steps at around 650 and 800 K. The O 1s core level spectra show both  $\text{O}_{2\text{ad}}$  and *two*  $\text{O}_{\text{ad}}$  species. In the presence of  $\text{H}_2$ , the formation of  $\text{H}_2\text{O}_{\text{ad}}$  occurs at around 150 K.  $\text{H}_2\text{O}_{\text{ad}}$  desorbs above 200 K.

The presence of  $\text{O}_{\text{ad}}$  enhances  $\text{NH}_{3\text{ad}}$  dissociation. Hydrogen abstraction starts at around 150 K, and  $\text{H}_2\text{O}_{\text{ad}}$  formed in this process desorbs above 200 K.  $\text{N}_2$  desorption occurs between 200 and 500 K.  $\text{NO}_{\text{ad}}$  and  $\text{NO}(\text{g})$  formation are also observed, but only during experiments where a large amount of  $\text{O}_{\text{ad}}$  is available.  $\text{NO}_{\text{ad}}$  desorbs/decomposes between 400 and 500 K, and both  $\text{NO}(\text{g})$  and  $\text{N}_2(\text{g})$  are observed in this temperature region.

The steady-state reaction between  $\text{NH}_3$  and  $\text{O}_2$  leads to  $\text{N}_2$  and  $\text{H}_2\text{O}$  formation, but at higher temperature the selectivity changes toward NO and  $\text{H}_2\text{O}$ . The exact temperature at which the selectivity change occurs depends strongly on the reactant ratio. The selectivity change is accompanied by a change in surface coverage;  $\text{N}_2$  is formed when the surface is  $\text{NH}_{\text{xad}}$ -covered, and NO is formed when the surface is  $\text{O}_{\text{ad}}$ -covered. We have compared our results with literature data for other Pt surfaces as well as results obtained on Ir surfaces. We propose that the main difference between Pt and Ir catalysts lies in the lower NO formation rate on Ir, rather than in a higher NO decomposition rate.

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